



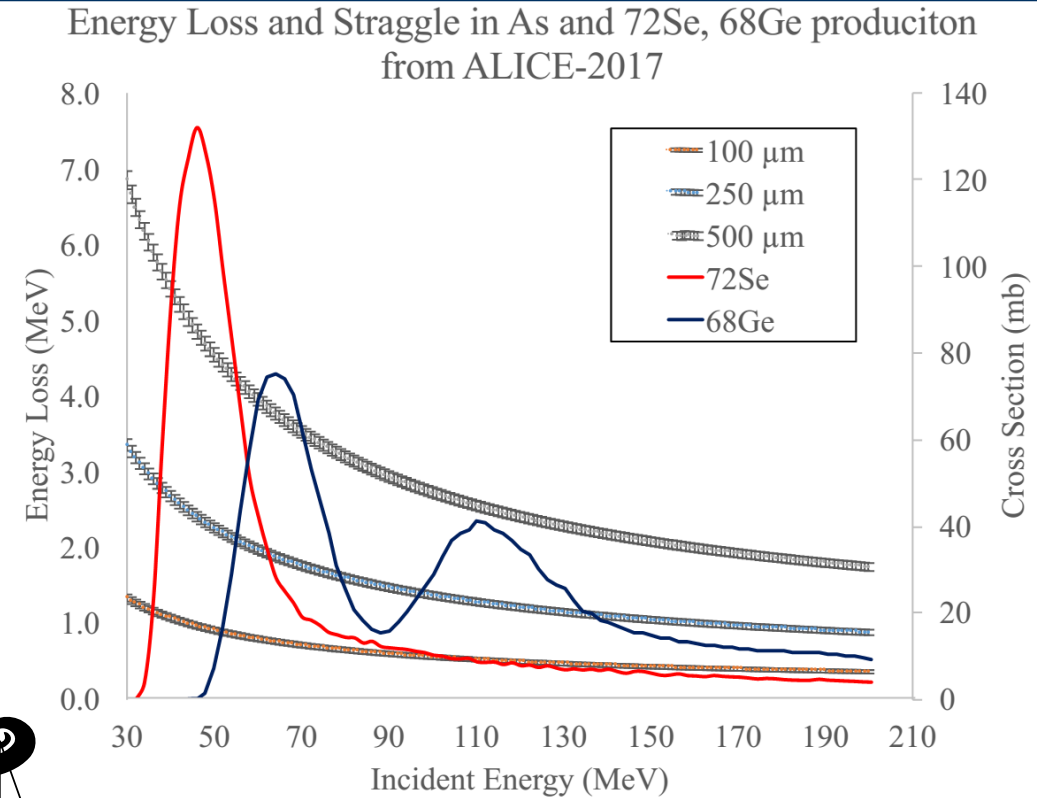
# Targetry Fabrication for Nuclear Data Measurements: What Works (and what doesn't!)



# The Targetry “Balancing Act”

34	<sup>70</sup> Se 41.1 m	<sup>71</sup> Se 4.74 m	<sup>72</sup> Se 8.40 d	<sup>73</sup> Se 39.8 m / 7.15 h	<sup>74</sup> Se 0.89%	<sup>75</sup> Se 119.78 d	<sup>76</sup> Se 9.37%
	<sup>69</sup> As 15.2 m	<sup>70</sup> As 52.6 m	<sup>71</sup> As 65.30 h	<sup>72</sup> As 26.0 h	<sup>73</sup> As 80.30 d	<sup>74</sup> As 17.77 d	<sup>75</sup> As 100.0%
32	<sup>68</sup> Ge 270.93 d	<sup>69</sup> Ge 39.05 h	<sup>70</sup> Ge 20.57%	<sup>71</sup> Ge 11.43 d	<sup>72</sup> Ge 27.45%	<sup>73</sup> Ge 7.75%	<sup>74</sup> Ge 36.50%
	<sup>67</sup> Ga 3.2617 d	<sup>68</sup> Ga 67.845 m	<sup>69</sup> Ga 60.108%	<sup>70</sup> Ga 21.14 m	<sup>71</sup> Ga 39.892%	<sup>72</sup> Ga 14.025 h	<sup>73</sup> Ga 4.86 h
30	<sup>66</sup> Zn 27.73%	<sup>67</sup> Zn 4.04%	<sup>68</sup> Zn 18.45%	<sup>69</sup> Zn 13.756 h / 56.4 m	<sup>70</sup> Zn 0.61%	<sup>71</sup> Zn 4.125 h / 2.45 m	<sup>72</sup> Zn 46.5 h
	36	38	40	42			

**Goal: 25-50  $\mu\text{m}$  thickness  
(~13-26  $\text{mg}/\text{cm}^2$ )**



- Goodfellow / AlfaAesar / Sigma:
  - Only bulk “lumps” ~20mm
- American Elements: < 10  $\mu\text{m}$  or > 2 mm
  - Communication issues...

- Semiconductor Industry: 5—1000+ mm
  - GaAs / GeAs
- Plasma Deposition: < ~10 mm

# In-House Fabrication: What Doesn't Work

**Arsenic is a near-perfect example of when common fabrication techniques are inapplicable**

- Three major allotropes:
  - Gray arsenic: semi-metallic, brittle
  - Yellow arsenic: waxy, rapidly oxidizes
  - Black arsenic: glassy, brittle
- Cold / hot rolling, extrusion causes significant cracking
- Impossible to cast – arsenic sublimates upon heating!
- Machining, laser/water cutting destroys bulk substrate
- Highly toxic, very difficult to fully remediate contamination with bulk quantities



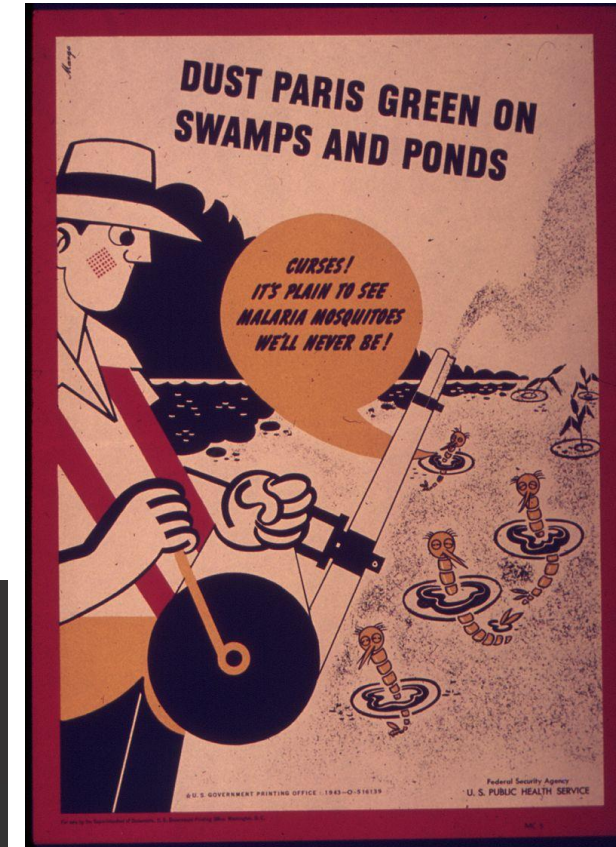
## HISTORY



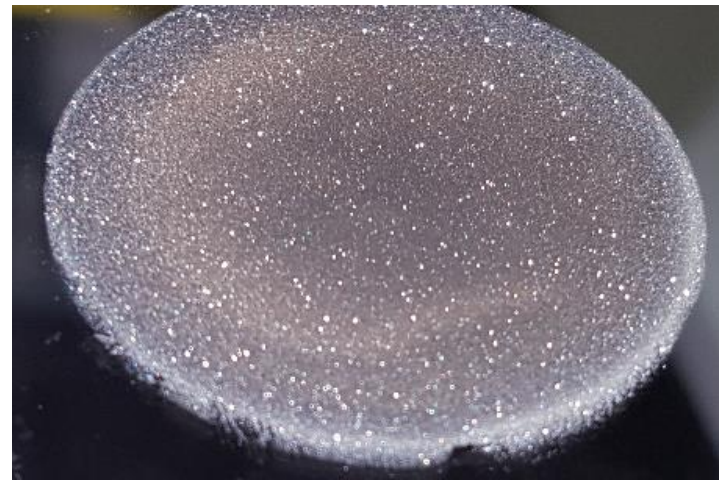
White arsenic has been known for centuries. In Ancient Rome, Nero's supposed use of it to poison his brother & become emperor is one of the first documented cases.



In the 17<sup>th</sup> & 18<sup>th</sup> centuries, white arsenic's use as a poison was widespread, and earned it the nickname 'inheritance powder'. However, its usage as a poison rapidly declined after the development of chemical tests.

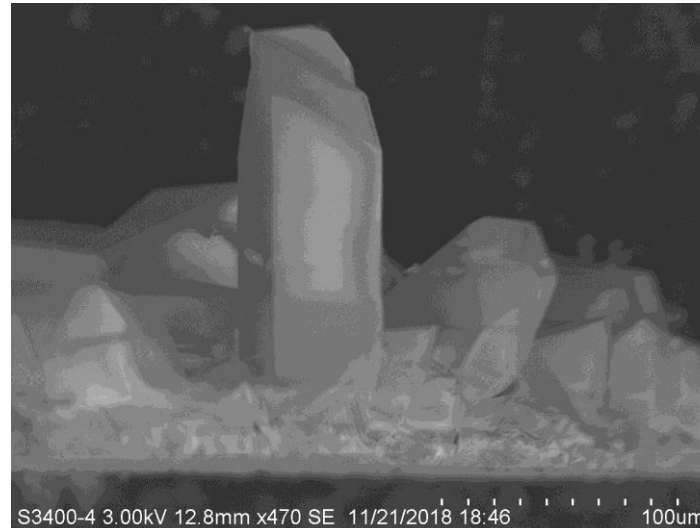


# In-House Fabrication: What (Almost) Works



Glass slide cover

Glass vial w/~1 g As



## Vapor deposition of As @ ORNL

- **New As stock is crucial** –  $\text{As}_2\text{O}_3$  from old material deposits preferentially
- Produces bulk crystalline structure
- Difficult to lift target from glass slide support without causing cracks
  - Deposition straight onto Kapton avoids this!
- Quick and easy preparation method!
  - Targets  $> 50\mu\text{m}$  crack from stress
  - Targets  $< 50\mu\text{m}$  have pinholes and thin spots visible to naked eye
- Deposition onto thin copper foil appears promising, but needs more investigation
  - Can revisit if interest / need exists!

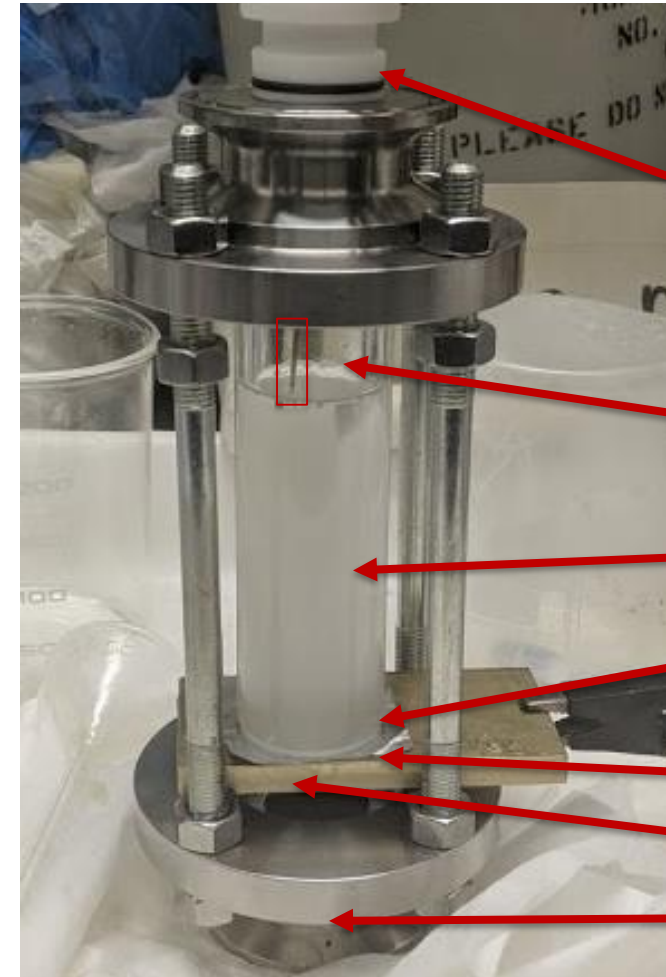
**Targets are currently not sufficiently uniform for nuclear data measurements**



# In-House Fabrication: What Does Work

[1] JRNC 282.2  
(2009): 365-368.

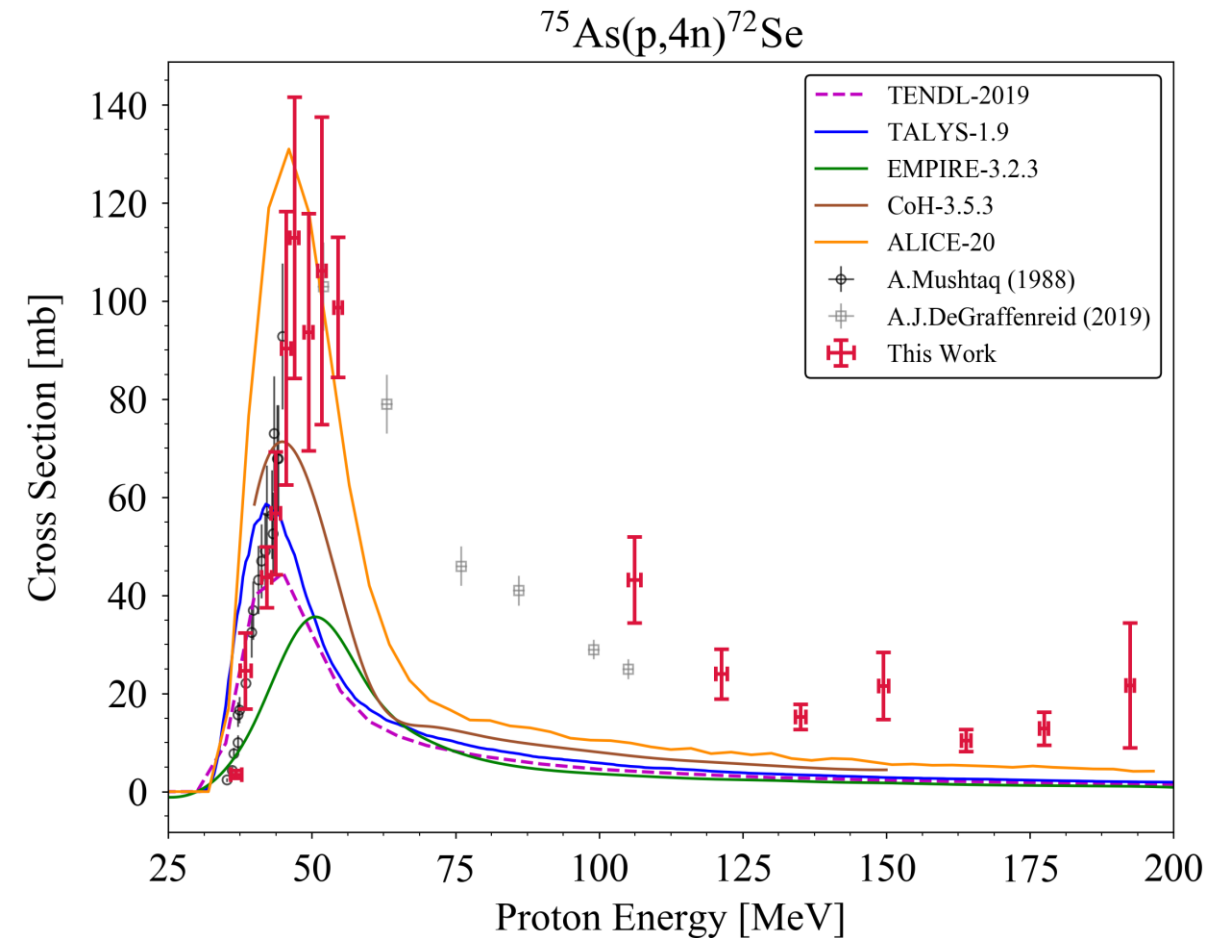
- Deposition onto 10um titanium foil<sup>1</sup>:
  - $\text{As}_2\text{O}_3$  (12.5 g/L) in 7M HCl, @ 130 mA



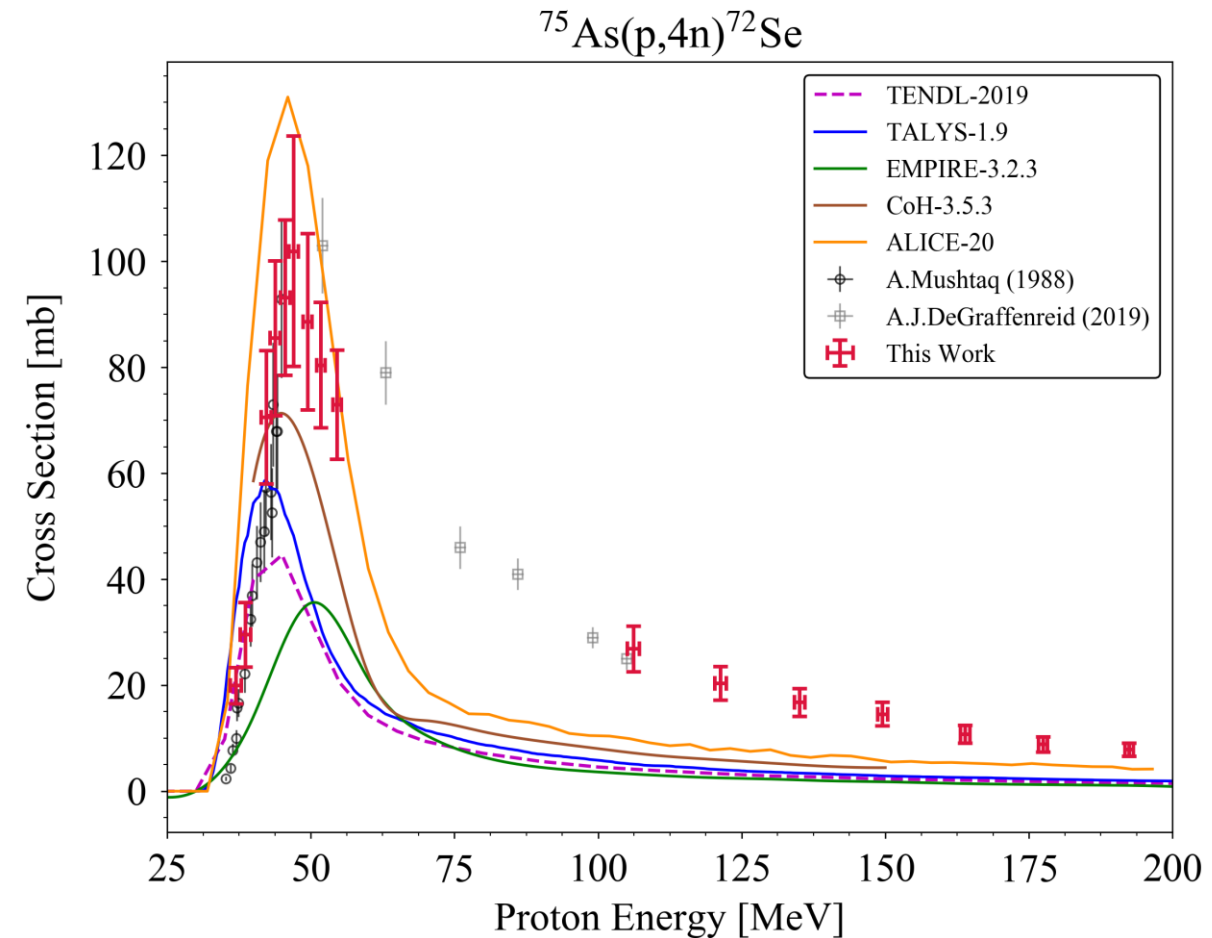
Developed plating capabilities with masses ranging 2-17 mg (approximately 1-10  $\mu\text{m}$ , or 0.5-4.5  $\text{mg}/\text{cm}^2$ )  
– uniform thickness within 2%,  $\Delta E_p < 80 \text{ keV}$

Major drawbacks: thickness characterization, difficult to plate  $> 10 \mu\text{m}$  without developing significant stress & flaking

# In-House Fabrication: What Does Work



Thickness via mass measurement



Thickness via reactor activation



# In-House Fabrication: What Could Work?

Additional deposition methods:

- $\text{As}_2\text{O}_3$  (0.2M) in 1:2 molar choline chloride : ethylene glycol deep eutectic solvent<sup>1</sup>, @46 mA
- Aluminum backing foil reduces  $\gamma$  background!
- Produces visually attractive target, but unknown composition...

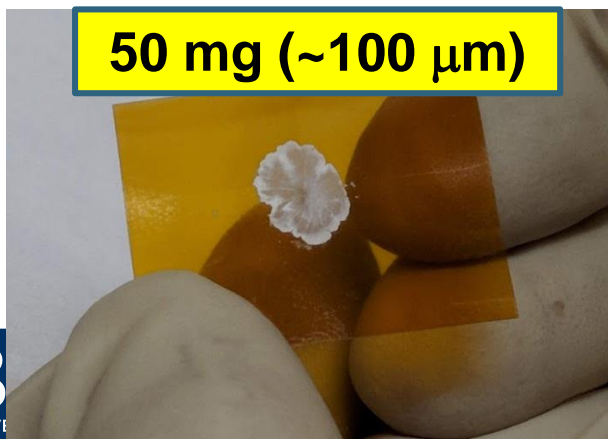


Powder pressing via hydraulic press and trapezoidal dies:

- For  $\varnothing > 5\text{mm}$ , difficult for targets  $< 100\mu\text{m}$
- At  $\varnothing = 10\text{mm}$ , easy to prepare targets  $> 250\mu\text{m}$
- $\text{As}_2\text{O}_3$  presses nicely, As requires binder
- Non-ideal for data measurements, but potentially viable for production targets?

50 mg (~100  $\mu\text{m}$ )

500 mg (~1 mm)



Vibrational / Electrostatic Powder Pressing<sup>2</sup>

- Relatively new technique, currently being used to explore Ti production target fabrication<sup>3</sup>
- Very efficient! Typical 95-98% sample utilization
- Scoping out prototype designs w/ UW (E. Dorman)

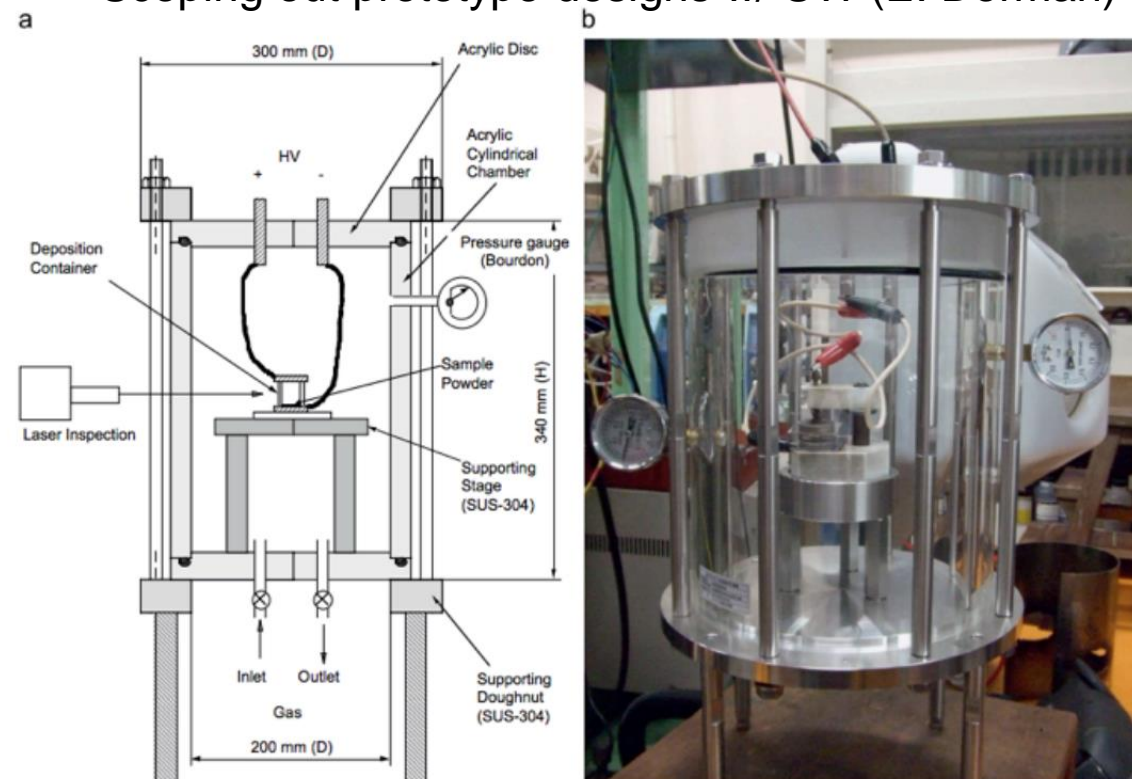


Fig. 2. (a) Cross-sectional drawing of the HIVIPP chamber for high-pressure operation and (b) a photograph.

[1] *J Electrochemical Society* 164.4 (2017): D204-D209.

[2] *NIM A* 397.1 (1997): 81-90.

[3] *Molecules* 24.1 (2019): 20.

# Collaborators on this Work

L.A. Bernstein<sup>1,2</sup>, E.R. Birnbaum<sup>3</sup>, C.S. Cutler<sup>4</sup>, M. Fox<sup>2</sup>, D. Medvedev<sup>4</sup>,  
J.T. Morrell<sup>2</sup>, F.M. Nortier<sup>3</sup>, E.M. O'Brien<sup>3</sup>, C. Vermeulen<sup>3</sup>, A.S. Voyles<sup>2</sup>, M.P. Zach<sup>5</sup>

<sup>1</sup> Lawrence Berkeley National Laboratory

<sup>2</sup> University of California-Berkeley Dept. of Nuclear Engineering

<sup>3</sup> Los Alamos National Laboratory

<sup>4</sup> Brookhaven National Laboratory

<sup>5</sup> Oak Ridge National Laboratory



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**ENERGY**

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